

## **POSSIBILITY OF CONSTRUCTING ELECTRONIC DEVICES WITH DIMENSIONS ON THE NANOMETER SCALE**

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### **Abstract**

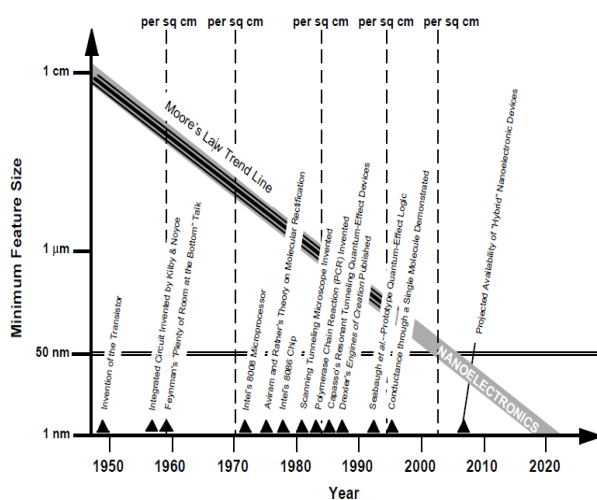
*This study reviews research developments aimed at the design of electronic computers that contain components with dimensions of only a few nanometers. A nanometer, one billionth of meter, is only about 10 atomic diameters. Such nanometer scale electronic computers {i.e., electronic nanocomputers} that contain molecular-scale components are likely to be up to 10,000 times more densely integrated than today's smallest microcomputers. Electronic technology is one of several alternative technologies (e.g., mechanical, chemical, quantum) that have been proposed for implementing a nanocomputer. Electronic technology for nanometer-scale computers has the advantage, though, that it builds upon nearly a half century of experience and infrastructure developed for electronic computing. Electronic nanocomputers could be orders of magnitude faster than current electronic computers, as well as many times smaller or more densely integrated.*

### **1. Introduction**

For the past forty years, electronic computers have grown more powerful as their basic subunit, the transistor, has shrunk. However, the laws of quantum mechanics and the limitations of fabrication techniques soon will prevent further reduction in the minimum size of today's semiconductor transistors. Researchers have projected that once the smallest features of the transistor's design shrink to less than 0.1 micrometers (or microns, millionths of a meter), the devices no longer will function usefully. In order to continue this miniaturization down to the molecular scale, present-day microelectronic device designs must be replaced with new designs that take advantage of the quantum mechanical effects that dominate on such a small scale.

There are a number of obstacles to making molecular scale electronic computer devices. What will they look like? Upon what operating principles will they function? How will individual devices be connected together? Once designed, how will these computers be fabricated? This paper addresses these questions by reviewing the literature about ongoing

research on the design of electronic computers integrated on the molecular scale. The authors have attempted to articulate a vision of future directions for the field based upon present developments. This vision and the answers to the questions above are presented in nonmathematical terms intended for a general, technically interested readership. However, this review article builds upon several, more technical and more specialized overviews and treatises that have preceded the present effort.



**Fig.1: Genesis of Nanotechnology**

Molecular-scale electronic devices will measure less than 100 nanometers on a side. One nanometer (one billionth of a meter) is a linear distance spanning approximately ten atomic diameters. By way of comparison, the smallest features on today's commercially available, state-of-the-art integrated circuits have linear dimensions of about three hundred fifty nanometers (0.35 microns) [50,284]. If a transistor could be made with a 1 nanometer minimum feature size (the dimension of the smallest feature on a device), over 10,000 of such nanodevices" would fit into the same area as a present day transistor. In other words, an electronic computer made of such nanometer-scale components {i.e., a nanocomputer" could be many orders of magnitude more powerful than today's microcomputers.

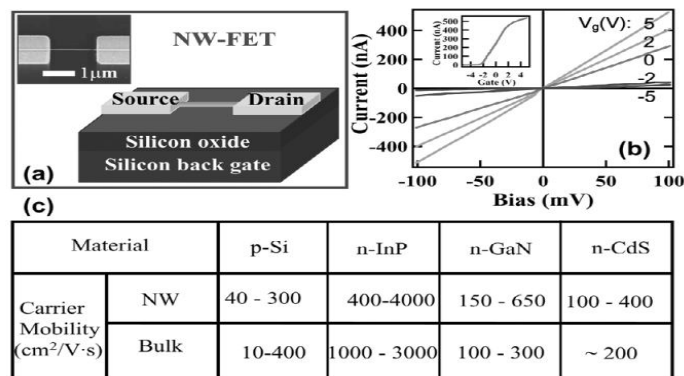
**2. Nanoelectronic Two-State Devices**

Electronic nanocomputers could possess the advantages of high speed and low power consumption. Such features would make them technically and economically desirable for a new range of applications. This potential has been an enormous stimulus to research and development and has produced significant new advances at an increasing rate.

**Table 1: Summary of Nanoelectronic Two-State Devices**

Device	Operating Principle	Status	Advantages	Disadvantages
Resonant Tunneling Transistor	Quantum resonance in double barrier potential wells	Capable of large scale fabrication	Logic compression Semiconductor based	Limits on scaling similar to microelectronics
Single electron transistor	Coulomb blockade	Experimental; only operates at very low temperatures	High gain operations principle	low temperature
Atom relay	Vibrational movement of a single atom in and out of an atom wire	Theoretical	Very high speed	Low temperature

These advances have resulted from a synthesis of technical developments in diverse fields. Mathematical and computer modeling have shown that electronic nanodevices are possible. In recent years, these new devices have been the subject of much speculation and research. Recent advances in the fields of physics, chemistry, molecular biology and electrical engineering have introduced tools and technologies of sufficient sensitivity that the fabrication of prototype nanodevices has begun.



**Fig. 2 Nanowire electronic properties**

The basic electronic properties of NWs can be characterized using electrical transport studies in a nanowire field effect transistor (NW-FET) configuration. The NW-FETs are prepared by dispersing a suspension of NWs in ethanol onto the surface of an oxidized silicon substrate, where the underlying conducting silicon is used as a global back gate. Source and drain electrodes are defined by electron beam lithography followed by electron beam evaporation of metal contacts, and electrical transport measurements are done at room temperature. Current (I) vs. source-drain voltage (V<sub>sd</sub>) and I vs. gate voltage (V<sub>g</sub>) is then recorded for an

NW-FET to characterize its electrical properties. Gate sweeping measurement of the NW-FET enables elucidation of important qualitative and quantitative properties of NWs. For example, changes in  $V_g$  produce variations in the electrostatic potential of the NW, and hence modulate the carrier concentration and conductance of the NW. Depending on the conductance modulation, it is possible to determine the doping type and estimate the carrier mobility in individual NWs using standard transistor formula:  $dI/dV_g = \mu(C/L^2)V_{sd}$  and  $C \cong 2\pi\epsilon_0L/\ln(2h/r)$ , where  $\mu$  is the carrier mobility,  $C$  is the capacitance,  $\epsilon$  is dielectric constant,  $h$  is the thickness of the SiO<sub>2</sub> dielectric,  $L$  is the length, and  $r$  is radius of the NW [42]. In this way, we have characterized a broad range of NW materials including p-type Si, n-type GaN, CdS, and InP NWs. In all cases, the NW materials show excellent carrier mobility comparable to bulk materials which demonstrates the high quality of these materials.

### **3. Objectives**

The main objective of this study is the development of theoretical and experimental methods for the controlled manipulation of surfaces at the nanometer scale, including the design, construction and experimental demonstration of an atomic force microscope (AFM) based manipulator. Different experimental and control techniques have been combined in the NanoManipulator system to optimize AFM lithography. Optical video microscopy allows a fast recognition of the sample and exact positioning of the AFM tip in the particular region of interest, while UV-laser ablation offers the possibility of noncontact manipulation of a wide range of materials, including biological specimens.

### **4. Hypotheses**

Self-assembly techniques that allow the controlled growth of nanometer-scale organic molecular films present new opportunities to develop electronic devices with dimensions much smaller than those of current technologies. In this thesis we address several of the challenges to realizing this goal, and demonstrate a molecular-scale programmable-resistance memory device.

Although technologically attractive, field-effect transistors (FETs) with a self-assembled organic channel are difficult to realize due to the poor gate-channel coupling. We have used electrostatic modeling to determine guidelines that allow the maximum gate modulation of the channel potential in these devices.

### **5. Conclusion**

The rapid miniaturization of electronics to the submicron scale has led to remarkable increases in computing power, while at the same time enabling cost reductions. However, as

the microelectronic industry advances toward ever smaller devices, it is believed that both physical and economic factors of current top-down silicon technology will soon limit further advances. To go beyond these limits and fuel the expected demands of future society will require revolutionary breakthroughs rather than current evolutionary progress. In general terms, bottom-up assembled nanoscale electronics could provide unparalleled speed, storage, and size reductions and hold the promise of powering future electronic devices that can outperform existing devices and open up totally new opportunities. To enable integrated nanoelectronics will require conceptually new device building blocks, scalable circuit architectures, and fundamentally different fabrication strategies. A bottom-up approach, where functional electronic structures are assembled from chemically synthesized, well-defined nanoscale building-blocks, has the potential to go far beyond the limits of top-down technology by defining key nanometer-scale metrics through chemical synthesis and subsequent assembly not by lithography.

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